

Docket No.: H0002769 (PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Hoki Kwon

Customer No.: 000128

Application No.: 10/078,474

Confirmation No.: 48

Filed: February 21, 2002

Art Unit: 2828

For:

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REFLECTOR ON INP

Examiner: Dung T. Ngu

INFORMATION DISCLOSURE STATEMENT (IDS)

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Pursuant to 37 CFR 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO/SB/08. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is filed more than three months after the U.S. filing date, OR more than three months after the date of entry of the national stage of a PCT application, AND after the mailing date of the first Office Action on the merits, whichever occurs first, but before the mailing date of a Final Office Action or Notice of Allowance (37 CFR 1.97(c)).

A copy of each non US patent references on the PTO/SB/08 is attached.

In accordance with 37 CFR 1.97(g), the filing of this Information Disclosure Statement shall not be construed to mean that a search has been made or that no other material information as defined in 37 CFR 1.56(a) exists. In accordance with 37 CFR 1.97(h), the filing

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of this Information Disclosure statement shall not be construed to be an admission that any patent, publication or other information referred to therein is "prior art" for this invention unless specifically designated as such.

It is submitted that the Information Disclosure Statement is in compliance with 37 CFR 1.98 and the Examiner is respectfully requested to consider the listed references.

Our check in the amount of \$180.00 covering the fee set forth in 37 CFR 1.17(p) is enclosed. The Director is hereby authorized to charge any deficiency in the fees filed, asserted to be filed or which should have been filed herewith (or with any paper hereafter filed in this application by this firm) to our Deposit Account No. 01-1125, under Order No. H0002769. A duplicate copy of this paper is enclosed.

Dated: February 6, 2004

Respectfully submitted,

Song/K. Jung

Registration No./35,21/

M¢KENNA LONĠ & ALDRIDGE LLP 1900 K Street, N.W.

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Attorney for Applicant

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PTO/SB/08A (04-03)

Approved for use 04-30-2003. OMB 0651-0031

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COMPLETE IF KNOWN Substitute for form 1449A-PTO Application Number 10/078,474 INFORMATION DISCLOSURE **Filing Date** 2-21-02 STATEMENT BY APPLICANT FEB 0 6 2000 First Named Inventor Ho Ki Kwon Art Unit 2828 (USE AS MANY SHEETS AS NECESSARY) Examiner Name Dung T. Nguyen H0002769 Attorney Docket Number

				U.S. PATE	NT DOCUMENTS	
Examiner Initials*	Cite No ¹	Document I	Kind Code ²	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
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	+	US 4608697		08-26-1986	Coldren	
 		US 4622672		11-11-1986	Coldren et al.	
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Examiner	D-4-	
Signature	Date Considered	

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Substitute for form 1449B-PTO	СОМ	PLETE IF KNOWN	MPE
	Application Number	10/078,474	
INFORMATION DISCLOSURE	Filing Date	2-21-02	
STATEMENT BY APPLICANT	First Named Inventor	Ho Ki Kwon	FEB U 6 ZOUM
(USE AS MANY SHEETS AS NECESSARY)	Group Art Unit	2828	<u>}</u>
Sheet 2 Of 8	Examiner Name	Dung T. Nguyen	(DADENARY
	Attorney Docket Number	H0002769	- AUEN

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Substitute for form 1449B-PTO	COMP	LETE IF KNOWN	OTPE
	Application Number	10/078,474	र्थ
INFORMATION DISCLOSURE	Filing Date	2-21-02	EED 0 0 0004
STATEMENT BY APPLICANT	First Named Inventor	Ho Ki Kwon	FEB 0 8 2004 14
(USE AS MANY SHEETS AS NECESSARY)	Group Art Unit	2828	is the second of
Sheet 3 Of 8	Examiner Name	Dung T. Nguyen	MADEMARK
	Attorney Docket Number	H0002769	

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Examiner Signature		Date Considered		
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Sheet 4 Of 8				
	Sheet	4	Of	8

COMPLETE IF KNOWN OTPE						
Application Number	10/078,474	5				
Filing Date	2-21-02	9				
First Named Inventor	Ho Ki Kwon 🧏	FEB 0 6 2004 H				
Group Art Unit	2828					
Examiner Name	Dung T. Nguyen	PADEMARK				
Attorney Docket Number	H0002769					

				FOF	REIGN PATEN	T DOCUMENTS		
Examiner Initials*	Cite No ¹	Country Code ³	oreign Patent Doo Number ⁴	cument Kind Code ⁵ (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ⁶
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Examiner	Date	
Signature	Considered	

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Sheet	5	Of	8

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СОМР	PLETE IF KNOWN
Application Number	10/078,474
Filing Date	2-21-02
First Named Inventor	Ho Ki Kwon FEB 0 6 2004
Group Art Unit	2828
Examiner Name	Dung T. Nguyen
Attorney Docket Number	H0002769

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	OTHER PRIOR ART – NON PATENT LITERATURE DOCUMENTS				
Examiner Cite Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published					
	_	International Search Report, dated 08-09-2003, relative to PCT application No. PCT/US 03/05368, the foreign equivalent to the instant U.S. application 10/078,474			
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		/ ALMUNEAU, G., et al., "Improved electrical and thermal properties of InP-AlGaAsSb Bragg mirrors for long-wavelength vertical-cavity lasers", article, Oct 2000, pgs 1322-4, Vol. 12, No. 10, IEEE Photonics Technology Letters.			
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Examiner Signature			Date Considered	
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¹Applicant's unique citation designation number (optional). ²Applicant is to place a check mark here if English language Translation is attached.

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STATEMENT BY APPLICANT

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Group Art Unit 2828

Examiner Name

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COMPLETE IF KNOWN Application Number 10/078,474 Filing Date 2-21-02 FEB 0 6 2004 **First Named Inventor** Ho Ki Kwon Group Art Unit 2828 HADEM Dung T. Nguyen Examiner Name Attorney Docket Number H0002769

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First Named Inventor	Ho Ki Kwon	FEB 0 6 2004 H			
Group Art Unit	2828	KE.			
Examiner Name	Dung T. Nguyen	7 At			
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